	Application No.	Applicant(s)	
Notice of Allewshills	10/699,857	WANG, CHI S.	
Notice of Allowability	Examiner	Art Unit	
	Vinit H. Patel	1764	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED in this app or other appropriate communication GHTS. This application is subject to	olication. If not included will be mailed in due course. THIS	,
1. X This communication is responsive to 20 June 2005.			
2. The allowed claim(s) is/are <u>1-4 and 6-18</u> .			
3. ☐ Acknowledgment is made of a claim for foreign priority una) ☐ All b) ☐ Some* c) ☐ None of the:	nder 35 U.S.C. § 119(a)-(d) or (f).		
 Certified copies of the priority documents have 			
Certified copies of the priority documents have			
Copies of the certified copies of the priority do	cuments have been received in this	national stage application from the	
International Bureau (PCT Rule 17.2(a)).	•		
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		complying with the requirements	
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give	itted. Note the attached EXAMINER es reason(s) why the oath or declara	'S AMENDMENT or NOTICE OF tion is deficient.	
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.		
(a) ☐ including changes required by the Notice of Draftspers	on's Patent Drawing Review (PTO-	948) attached	
1) 🔲 hereto or 2) 🔲 to Paper No./Mail Date		. •	
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date	s Amendment / Comment or in the C	Office action of	
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t	.84(c)) should be written on the drawin he header according to 37 CFR 1.121(ngs in the front (not the back) of d).	
6. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT	SIT OF BIOLOGICAL MATERIAL REFORE THE DEPOSIT OF BIOLOGIC	nust be submitted. Note the AL MATERIAL.	
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Attachment(s)		•	
1. Notice of References Cited (PTO-892)	Notice of Informal P	atent Application (PTO-152)	
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview Summary Paper No./Mail Da		
3. Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date		ment/Comment	
4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. X Examiner's Stateme	ent of Reasons for Allowance	
or biological inacerial	9.		
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DETAILED ACTION

Allowable Subject Matter

Claims 1-4 and 6-18 are allowed.

The following is an examiner's statement of reasons for allowance: Plasma reformers for the dissociation of hydrocarbon fuel and water are generally known in the art. Applicant's invention is a plasma reformer having a turbulent heating zone containing micro-porous articulated material with a ceramic wall, a reaction chamber having electrode means attached to the ceramic wall, an inner wall containing collector electrodes, and an electric circuit between the emitter electrodes and collector electrodes; an energy retaining zone; low thermal conductive materials surrounding the energy retaining zone; compression-expansion cushion mat surrounding the low thermal conductive material; an ion-neutralization filter surrounding the collector electrodes in the reaction chamber; a casing and ingress means into the turbulent zone and egress means from the energy retaining zone.

A search of the prior art revealed Wang, USP 5,614,156, Kieser et al., USP 5,746,051, Sakurai et al., USP 5,744,104 and Tuck et al., USP 6,097,139. However the prior art alone or in combination does not teach or suggest applicant's invention having a turbulent heating zone containing micro-porous articulated material with a ceramic wall, a reaction chamber having electrode means attached to the ceramic wall, an inner wall containing collector electrodes, and an electric circuit between the emitter electrodes and collector electrodes; an energy retaining zone; low thermal conductive materials surrounding the energy retaining zone; compression-expansion cushion mat

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surrounding the low thermal conductive material; an ion-neutralization filter surrounding the collector electrodes in the reaction chamber; a casing and ingress means into the turbulent zone and egress means from the energy retaining zone. Furthermore, Kieser et al., while teaching dielectric layers are utilized as insulating materials, does not disclose or suggest that a plasma reformer further comprise having an ion-neutralization filter surrounding the collector electrodes in the reaction chamber.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Vinit H. Patel whose telephone number is (571) 272-0856. The examiner can normally be reached on 9:00 am - 5:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Glenn Caldarola can be reached on (571) 272-1444. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Supervisory Patent Examine: Technology Center 1700